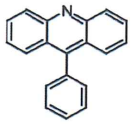
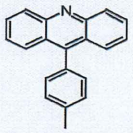
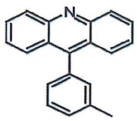
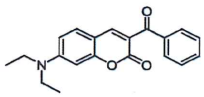
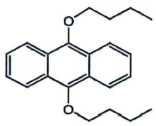
Photosensitizer

Product	Chemical Structure	Peak Absorption	Feature	Application
TR-PAD-101		250 nm，358 nm，385 nm	High curing speed	Photoresist
TR-PAD-102		250 nm，358 nm，385.5 nm	High curing speed	Photoresist
TR-PAD-103		249 nm，358 nm，385.5 nm	High curing speed	Photoresist
TR-PAD-107	Closed Information	253.5 nm, 385.5 nm	High solubility and curing speed	Photoresist
TR-PSS-202		251 nm, 323 nm, 422 nm	High photosensitivity and initiation efficiency, wide spectral response range	UV curing ink, photoresist
TR-PSS-205	Closed Information	382 nm	High performance coumarin sensitizer with prolonged maximum absorption wavelength of cationic initiator	UV curing formulation of cationic initiator
TR-PSS-303		259 nm, 365.5 nm 383 nm, 406 nm	Used in 184, BDK, PAG101, PAG102, etc.	UV curing ink, photoresist, welding mask and adhesives
TR-PSS-306	Closed Information	263 nm, 368.5 nm 385 nm, 407 nm	High solubility, available in enahncing surface property and cohesive force of products	Polymerization of thick film cationic system
TR-PSS-510	Closed Information	353.8nm，372nm，392.2nm	Suitable for LED curing of free radical and cationic system	Suitable for UV coating, UV ink, UV adhesive etc.,It has the advantages of high sensitivity, low yellowing and so on.
TR-PSS-603	Closed Information	262 nm，375 nm	High solubility and good resolution	Photocurable inks, photoresists, solder masks, electronic coatings, photocurable adhesives.